

Data Sheet July 1999 File Number 4589.1

Radiation Hardened 16 Channel CMOS Analog Multiplexer with High-Z Analog Input Protection

Intersil's Satellite Applications FlowTM (SAF) devices are fully tested and guaranteed to 100kRAD Total Dose. These QML Class T devices are processed to a standard flow intended to meet the cost and shorter lead-time needs of large volume satellite manufacturers, while maintaining a high level of reliability.

The HS-1840ARH-T is a Radiation Hardened, monolithic 16 channel multiplexer constructed with the Intersil Rad-Hard Silicon Gate, Dielectric Isolation process. It is designed to provide a high input impedance to the analog source if device power fails (open), or the analog signal voltage inadvertently exceeds the supply by up to ±35V, regardless of whether the device is powered on or off. Selection of one of sixteen channels is controlled by a 4-bit binary address plus an Enable-Inhibit input, which conveniently controls the ON/OFF operation of several multiplexers in a system. All inputs have electrostatic discharge protection.

Specifications

Specifications for Rad Hard QML devices are controlled by the Defense Supply Center in Columbus (DSCC). The SMD numbers listed below must be used when ordering.

Detailed Electrical Specifications for the HS-1840ARH-T are contained in SMD 5962-95630. A "hot-link" is provided from our website for downloading.

www.intersil.com/spacedefense/newsafclasst.asp

Intersil's Quality Management Plan (QM Plan), listing all Class T screening operations, is also available on our website.

www.intersil.com/quality/manuals.asp

Ordering Information

ORDERING NUMBER	PART NUMBER	TEMP. RANGE (°C)
5962R9563002TXC	HS1-1840ARH-T	-55 to 125
HS1-1840ARH/Proto	HS1-1840ARH/Proto	-55 to 125
5962R9563002TYC	HS9-1840ARH-T	-55 to 125
HS9-1840ARH/Proto	HS9-1840ARH/Proto	-55 to 125

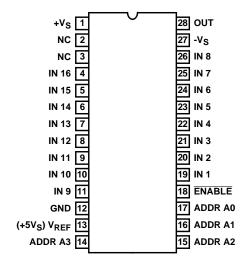
NOTE: Minimum order quantity for -T is 150 units through distribution, or 450 units direct.

Features

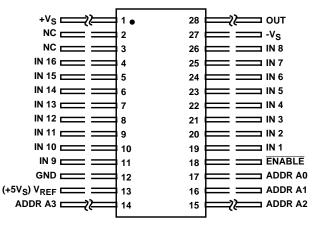
- QML Class T, Per MIL-PRF-38535
- · Radiation Performance
 - Gamma Dose (γ) 1 x 10⁵ RAD(Si)
 - No Latch-Up, Dielectrically Isolated Device Islands
- Improved r_{DS(ON)} Linearity
- Improved Access Time 1.5µs (Max) Over Temp and Rad
- High Analog Input Impedance 500MΩ During Power Loss (Open)
- ±35V Input Over Voltage Protection (Power On or Off)
- · Excellent in Hi-Rel Redundant Systems
- Break-Before-Make Switching

Pinouts

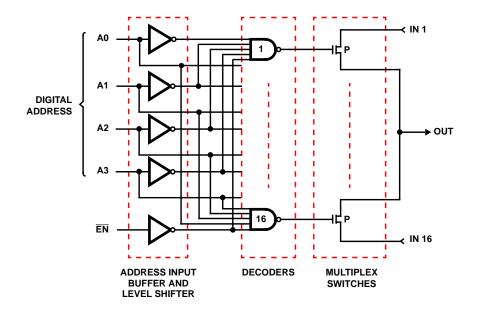
HS1-1840ARH-T (SBDIP), CDIP2-T28 TOP VIEW



HS9-1840ARH-T (FLATPACK) CDFP3-F28 TOP VIEW



Functional Diagram



TRUTH TABLE

А3	A2	A1	A0	EN	"ON" CHANNEL
Х	Х	X	Х	Н	None
L	L	L	L	L	1
L	L	L	Н	L	2
L	L	Н	L	L	3
L	L	Н	Н	L	4
L	Н	L	L	L	5
L	Н	L	Н	L	6
L	Н	Н	L	L	7
L	Н	Н	Н	L	8
Н	L	L	L	L	9
Н	L	L	Н	L	10
Н	L	Н	L	L	11
Н	L	Н	Н	L	12
Н	Н	L	L	L	13
Н	Н	L	Н	L	14
Н	Н	Н	L	L	15
Н	Н	Н	Н	L	16

Die Characteristics

DIE DIMENSIONS:

 $(2820\mu m\ x\ 4080\mu m\ x\ 483\mu m\ \pm 25.4\mu m)$ 111 x 161 x 19mils ± 1 mil

METALLIZATION:

Type: Al Si Cu

Thickness: 16.0kÅ ±2kÅ

SUBSTRATE POTENTIAL:

Unbiased (DI)

BACKSIDE FINISH:

Silicon

PASSIVATION:

Type: Nitride (Si_3N_4) over Silox (S_iO_2) Nitride Thickness: $4.0k\mathring{A} \pm 0.5k\mathring{A}$ Silox Thickness: $12.0k\mathring{A} \pm 1.3k\mathring{A}$

WORST CASE CURRENT DENSITY:

< 2.0e5 A/cm²

TRANSISTOR COUNT:

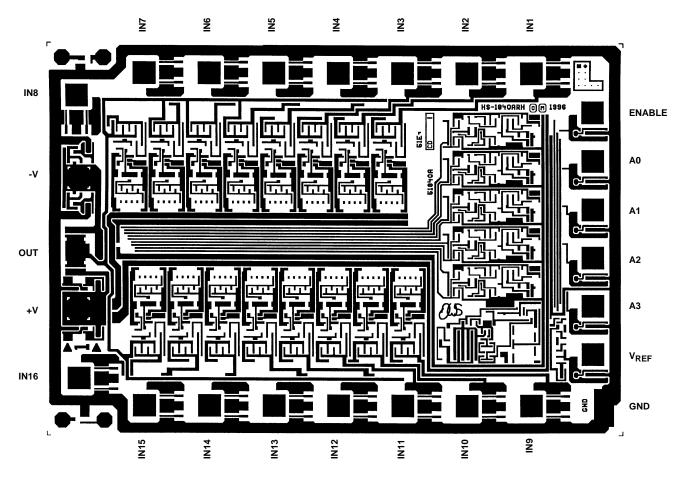
407

PROCESS:

Radiation Hardened Silicon Gate, Dielectric Isolation

Metallization Mask Layout

HS-1840ARH-T



All Intersil semiconductor products are manufactured, assembled and tested under ISO9000 quality systems certification.

Intersil semiconductor products are sold by description only. Intersil Corporation reserves the right to make changes in circuit design and/or specifications at any time without notice. Accordingly, the reader is cautioned to verify that data sheets are current before placing orders. Information furnished by Intersil is believed to be accurate and reliable. However, no responsibility is assumed by Intersil or its subsidiaries for its use; nor for any infringements of patents or other rights of third parties which may result from its use. No license is granted by implication or otherwise under any patent or patent rights of Intersil or its subsidiaries.

For information regarding Intersil Corporation and its products, see web site http://www.intersil.com